



US00D595841S

(12) **United States Design Patent**
McAuley et al.

(10) **Patent No.:** **US D595,841 S**
(45) **Date of Patent:** **** Jul. 7, 2009**

(54) **FULL FACE MASK**

(75) Inventors: **Alastair Edwin McAuley**, Auckland (NZ); **Craig Robert Prentice**, Auckland (NZ); **Wen Dong Huang**, Auckland (NZ); **Arvin San Jose Gardiola**, Auckland (NZ); **Mark McLaren**, Auckland (NZ)

(73) Assignee: **Fisher & Paykel Healthcare Limited**, Auckland (NZ)

(**) Term: **14 Years**

(21) Appl. No.: **29/326,044**

(22) Filed: **Oct. 10, 2008**

(51) **LOC (9) Cl.** **29-02**

(52) **U.S. Cl.** **D24/110.1; D24/110.4; D24/110.5**

(58) **Field of Classification Search** D24/110.1, D24/110.4, 110.5; 128/205.25, 206.27, 207.11, 128/206.26, 207.17, 207.13, 206.21, 204.18, 128/206.12

See application file for complete search history.

(56) **References Cited**

U.S. PATENT DOCUMENTS

D303,587 S	9/1989	Quinn et al.	
D305,166 S	12/1989	Quinn et al.	
D323,908 S	2/1992	Hollister et al.	
D349,586 S	8/1994	Handke	
D397,215 S	8/1998	Hoftman	
D476,732 S	7/2003	Smart	
D486,226 S *	2/2004	Guney et al.	D24/110.1
D492,992 S	7/2004	Guney et al.	
D493,885 S	8/2004	Raje et al.	
D506,827 S	6/2005	Jones et al.	
D507,831 S *	7/2005	Rosenkranz et al.	D24/110.1
6,926,004 B2	8/2005	Schumacher	
D555,785 S	11/2007	McAuley et al.	
D583,930 S	12/2008	McAuley et al.	
D584,400 S	1/2009	McAuley et al.	
D586,458 S *	2/2009	Kooij et al.	D24/110.1

2003/0034034 A1 2/2003 Kwok et al.
2008/0006277 A1 1/2008 Worboys et al.
2008/0257354 A1 10/2008 Davidson et al.
2008/0276937 A1* 11/2008 Davidson et al. 128/204.18

* cited by examiner

Primary Examiner—Ian Simmons
Assistant Examiner—Christopher Lee

(74) *Attorney, Agent, or Firm*—Trexler, Bushnell, Giangiorgi, Blackstone & Marr, Ltd.

(57) **CLAIM**

The ornamental design for a full face mask, as shown and described.

DESCRIPTION

FIG. 1 is a top plan view of the full face mask according to our design and shown attached to a headgear and connector which are in broken line;

FIG. 2 is a left side elevational view of the full face mask shown attached to the headgear and connector which are in broken line;

FIG. 3 is a front elevational view of the full face mask shown attached to the headgear and connector which are in broken line;

FIG. 4 is a right side elevational view of the full face mask shown attached to the headgear and connector which are in broken line;

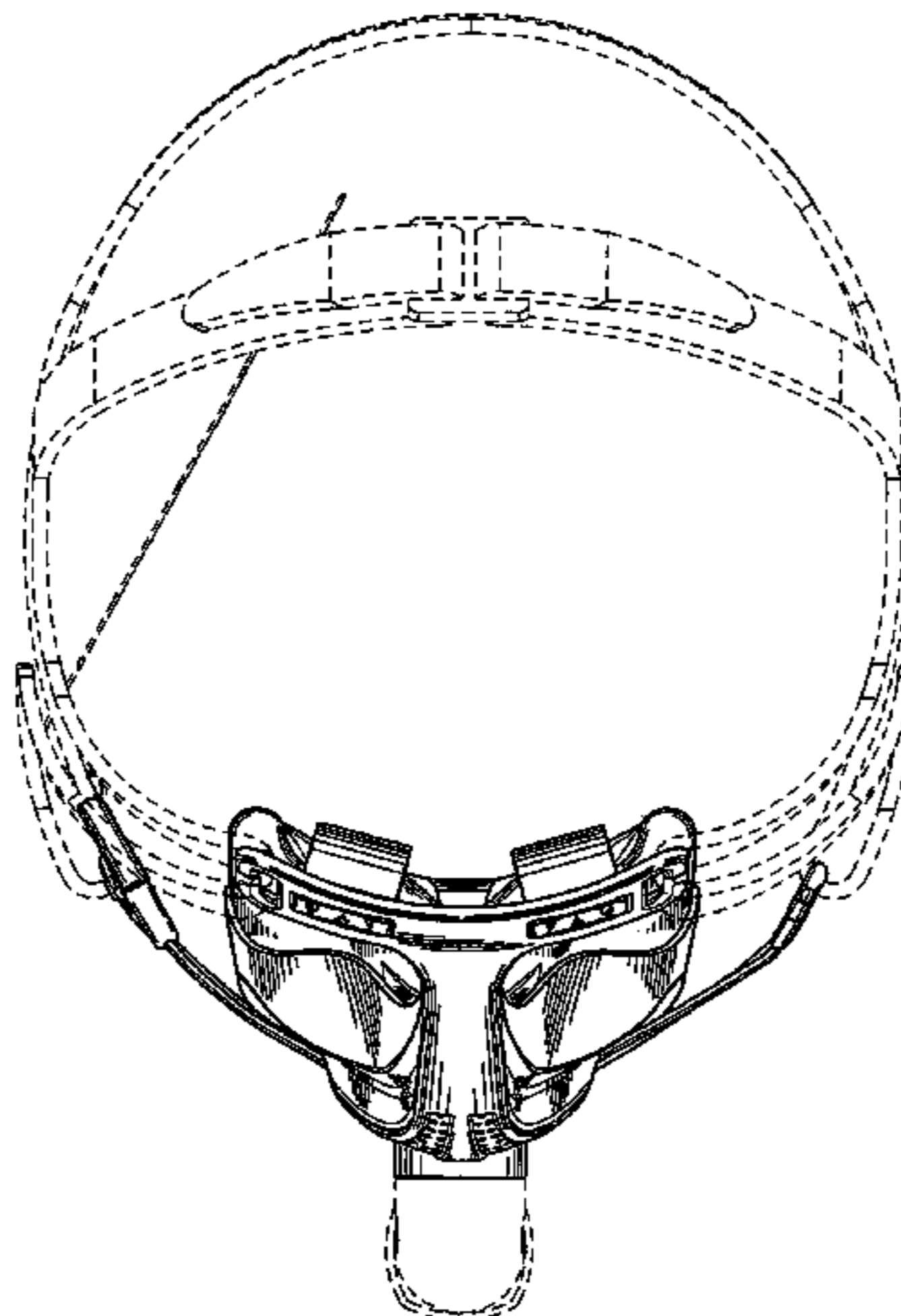
FIG. 5 is a rear elevational view of the full face mask shown attached to the connector which is in broken line;

FIG. 6 is a bottom plan view of the full face mask shown attached to a headgear and connector which are in broken line; and,

FIG. 7 is a right side perspective view of the full face mask and shown attached to a headgear and connector which are in broken line.

The broken lines in the drawings show environmental structure that form no part of the design to be patented.

1 Claim, 7 Drawing Sheets



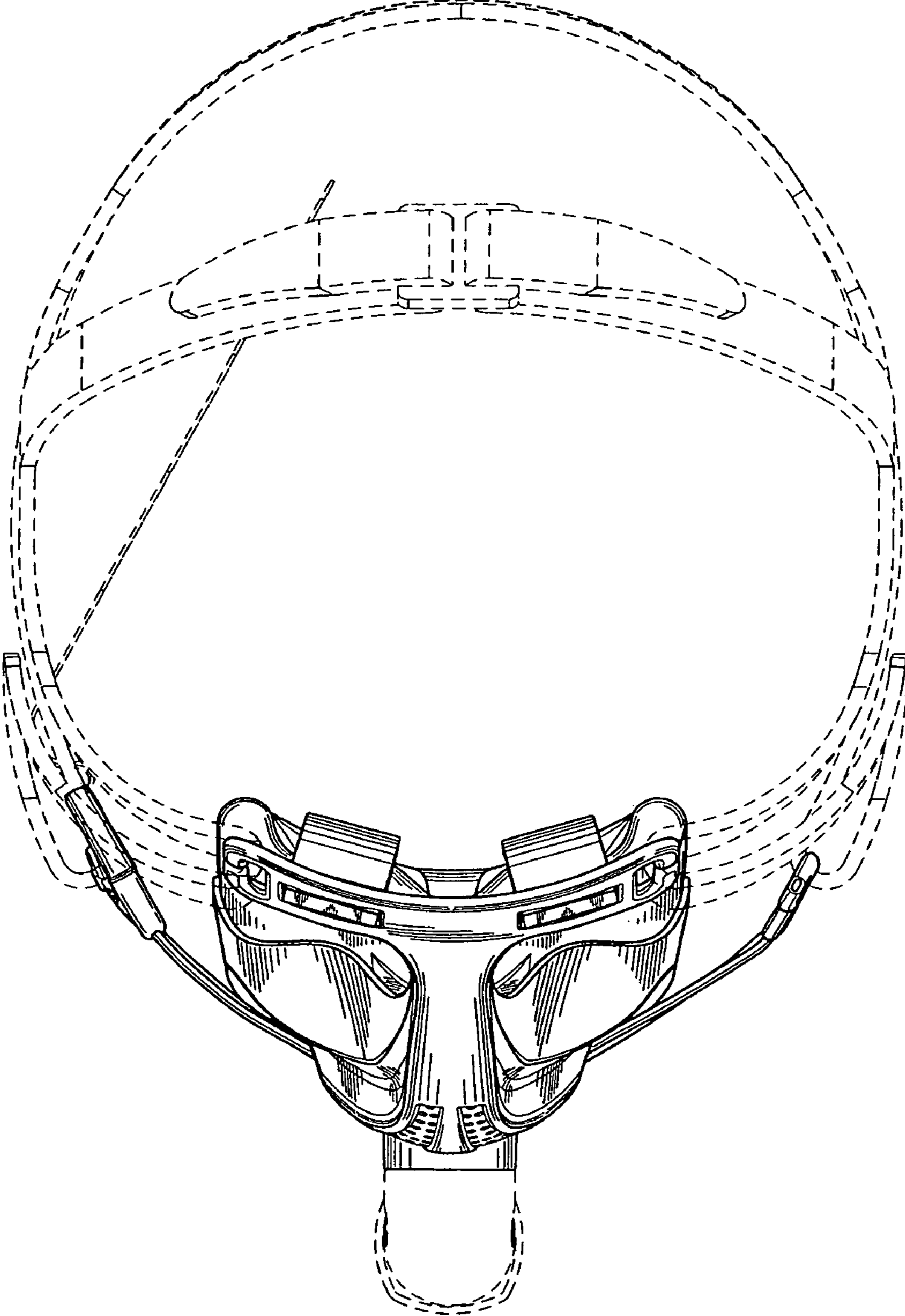


FIGURE 1

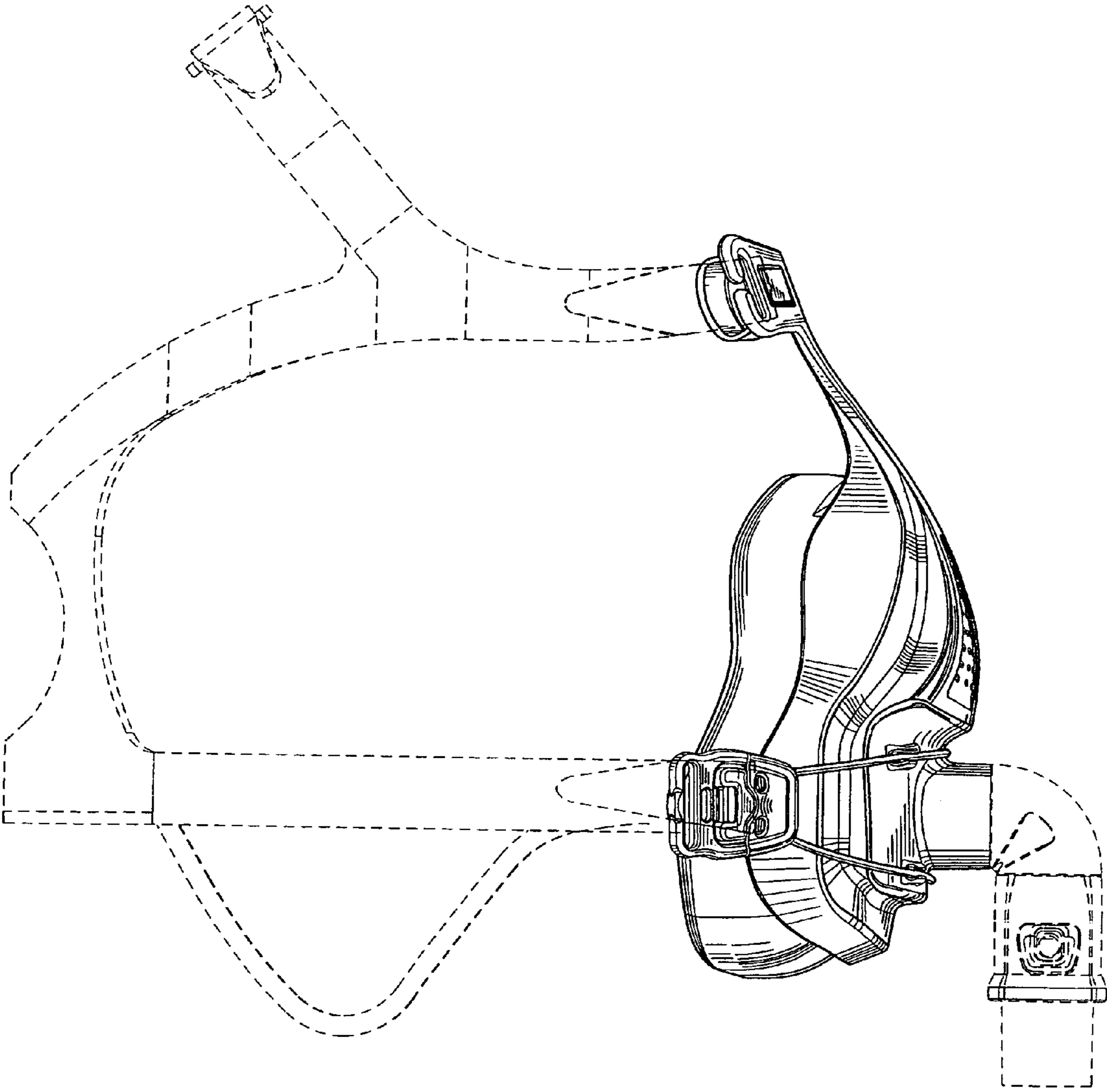


FIGURE 2

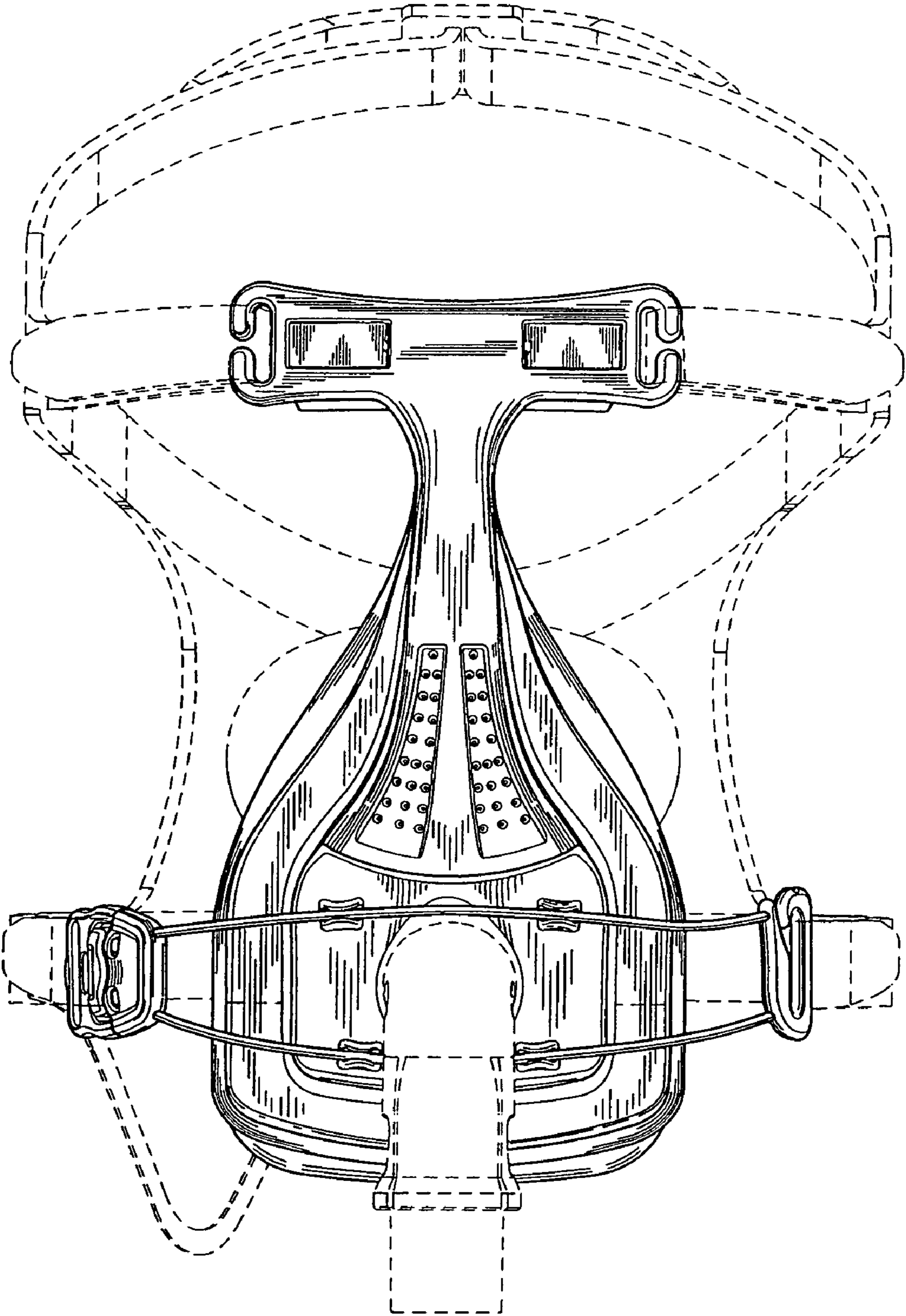


FIGURE 3

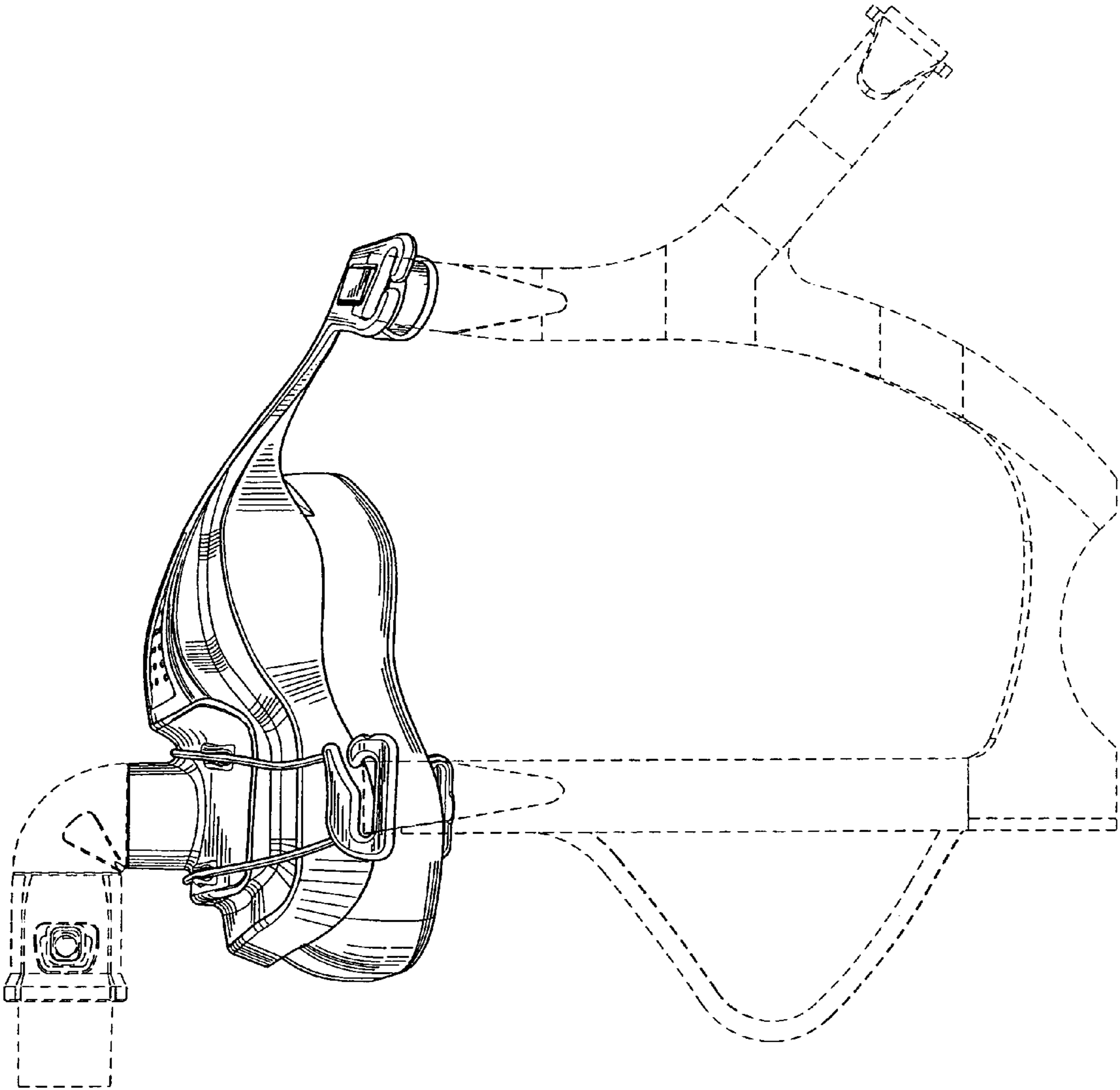


FIGURE 4

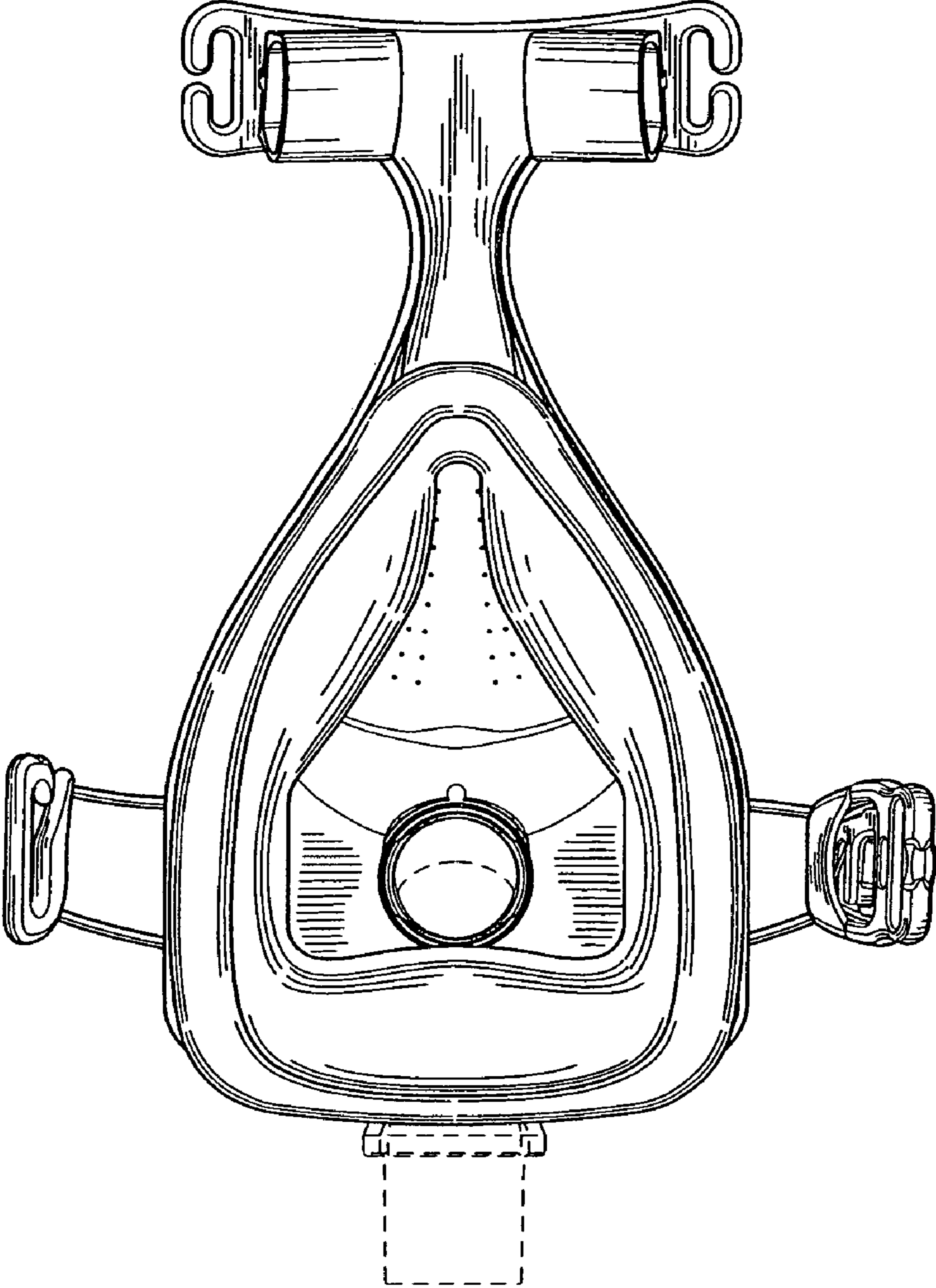


FIGURE 5

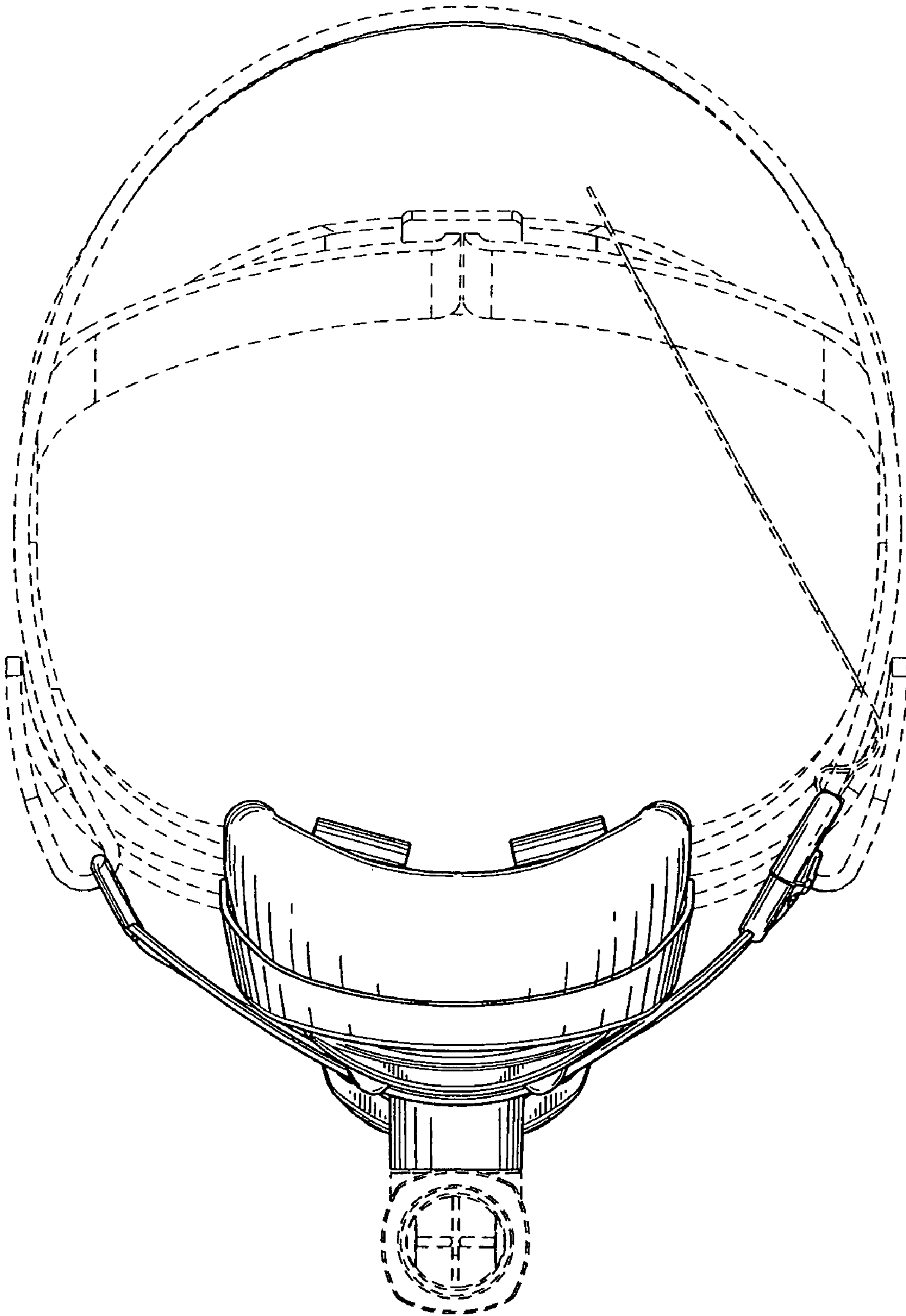


FIGURE 6

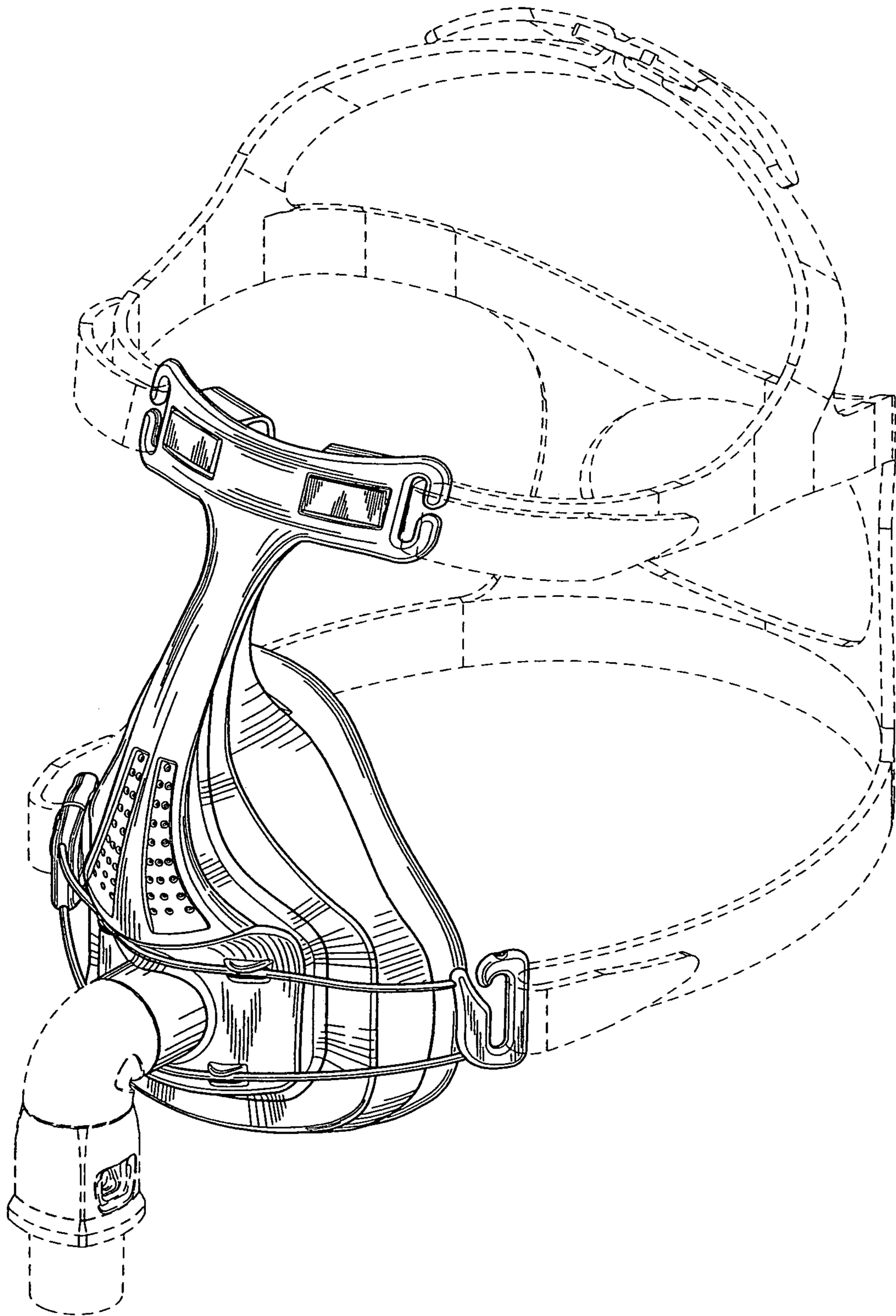


FIGURE 7